



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#12/A
1-15-02
DW

Application Number: 09/519,165
Filing Date: 03/06/2000
Applicants: Sherrer, et al.
Application Title: **Single Mask Lithographic Process for
Patterning Multiple Types of surface
Features**
Examiner: William P. Watkin, III
Art Unit: 1772
Docket No.: ACT-111

Commissioner of Patents and Trademarks
Washington, DC 20231

Sir:

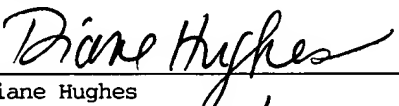
AMENDMENT A

In response to the office action mailed 07/17/01, kindly
amend the above application as follows:

DRAWINGS: No Changes

SPECIFICATION: No Changes

CLAIMS: Please amend claim 13. ✓
Please add claims 19-29.

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, DC 20231, on	
 Diane Hughes	<u>11/16/01</u> Date of Deposit
<u>11/16/01</u> Date	